

A pn-junction between chalcopyrite phosphide semiconductors for photovoltaic application

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Abstract

We report on the fabrication of pn-junction between II-IV-V₂ type compounds with chalcopyrite crystal structure such as CdSnP₂ and ZnSnP₂ for photovoltaic application. In the fabrication process, Cd-Sn precursor thin films were prepared on ZnSnP₂ bulk crystals grown by flux method and the precursor thin films reacted with phosphorus gas to form CdSnP₂/ZnSnP₂ junction. STEM-EDX analysis and SAED patterns revealed that CdSnP₂ was epitaxially grown on ZnSnP₂ bulk crystals, indicating that the favourable junction was obtained in the view point of carrier transport. In addition, Zn was also detected in the region of CdSnP₂ thin film due to the diffusion of Zn during phosphidation. This suggests the formation of solid solution (Cd,Zn)SnP₂ between ZnSnP₂ and CdSnP₂, leading to realization of *homo*junction. In the *J*–*V* measurements of the *n*-(Cd,Zn)SnP₂/*p*-ZnSnP₂ junction, a rectifying behavior was observed. The results in this work are cornerstones for photovoltaic application using II-IV-V₂ type compound semiconductors including phosphides.

1. Introduction

Thin film solar cells based on compound semiconductors are one of the promising candidates for the alternative to Si-based solar cells. For example, $\text{CuIn}_{1-x}\text{Ga}_x\text{Se}_2$ (CIGS) and CdTe recorded high efficiencies of 22.9%¹ and 22.1%², respectively, which are comparable to that of multicrystalline-Si solar cells, 22.3%³. However, the usage of rare or toxic elements, such as In, Ga, Cd and Te, prevents the widespread use of these compound semiconductors. Although chalcogenide compounds including S, Se and Te have been mainly researched in the field of thin film solar cells, II-IV-V₂ type pnictide compounds, such as ZnSnP_2 ⁴⁻⁶ and ZnSnN_2 ⁷⁻⁹ attract much attention as solar absorbing materials in recent years.

Our research group focused on ZnSnP_2 with the chalcopyrite structure, which has a suitable direct bandgap of 1.6 eV¹⁰⁻¹⁶ for photovoltaic devices. Based on the Shockley-Queisser limit,¹⁷ the theoretical conversion efficiency of about 30% is calculated in the single-junction solar cell using ZnSnP_2 under the condition of AM 1.5 G solar spectrum.¹⁸ In addition, the absorption coefficient of ZnSnP_2 was reported to be approximately 10^5 cm^{-1} in the visible light range,^{18,19} which enables thin film device. For electronic properties, non-doped ZnSnP_2 shows a p-type conduction with the carrier concentration of $10^{16} - 10^{18} \text{ cm}^{-3}$.¹⁰⁻¹⁶ The dominant intrinsic defects are antisite atoms reported based

on the first principle calculation by Kumagai et al.²⁰ Our research group also reported that ZnSnP₂ solar cells recorded 3.44 % with the structure of Al/Al-doped ZnO/ZnO/(Cd,Zn)S/ZnSnP₂/Cu. The cell parameters such as short circuit current density, J_{SC} , open circuit voltage, V_{OC} , and fill factor, FF , were 12.3 mA/cm², 0.472 V and 0.594, respectively.⁴ Considering the bandgap of ZnSnP₂, V_{OC} was largely lower than expected. The measurements by X-ray photoelectron spectroscopy (XPS) revealed a large conduction band offset, -1.2 eV at the heterojunction between CdS and ZnSnP₂.²¹ It is considered that (Cd,Zn)S used in the best cell also has a large conduction band offset with ZnSnP₂, which limits V_{OC} . Therefore, the improvement of the band offset in ZnSnP₂ solar cells is required.

In this study, CdSnP₂ was focused on as a *n*-type material alternative to (Cd,Zn)S. CdSnP₂ also has a chalcopyrite structure and a bandgap of 1.17 eV.²² Hinuma *et al.* carried out the first-principles calculation in ZnSnP₂, CdSnP₂ and related materials to obtain their band structures.²³ They revealed that the conduction band offset between CdSnP₂ and ZnSnP₂ was expected to be -0.5 eV. We thus consider an application of CdSnP₂/ZnSnP₂ pn-heterojunction to photovoltaics and investigate the diode characteristics and the interface structure with nanoscale.

2. Experimental method

CdSnP₂/ZnSnP₂ junction was prepared by the formation of CdSnP₂ thin film on the surface of ZnSnP₂ bulk crystal fabricated by flux method. The details of experimental condition for bulk crystal growth were well described in our previous work.¹² The raw materials such as zinc shots (99.99%, Kojundo Chemical Laboratory), tin shots (99.99%, Kojundo Chemical Laboratory) and red phosphorus flakes (99.9999%, Kojundo Chemical Laboratory) were sealed in an evacuated quartz ampule under the pressure of 10⁻² Pa. The nominal composition was determined to be 92 mol %Sn in Sn-ZnP₂ pseudo-binary system. Then, sample was unidirectionally solidified from the bottom with the average cooling rate of about 0.7 °C/h after heated up to 700 °C for homogenization. The grown ZnSnP₂ crystals were cut into several wafers in perpendicular to the growth direction. The surface of each wafer was mechanically polished to obtain mirror surface. And the ZnSnP₂ wafers were etched by immersing in 1/2 diluted aqua regia (HCl:HNO₃ = 3:1) for 15 min to remove the damaged layer derived from mechanical polishing.⁵

In our previous work, the fabrication process for CdSnP₂ thin films was already established using phosphidation method, where Cd-Sn precursor thin films react with phosphorus gas.²⁴ Cd-Sn thin films with the thickness of 100 nm were prepared as a

precursor on the polished and etched surfaces of ZnSnP_2 bulk crystals by co-deposition with DC magnetron sputtering using Cd (99.9 %, Kojundo Chemical Laboratory) and Sn (99.99%, Furuuchi Chemical Corporation) targets. The sputtering period was 15 min and the pressure of Ar gas was 0.8 Pa. Considering the higher vapor pressure of Cd, the molar ratio $[\text{Cd}]/[\text{Sn}]$ was controlled to be about 1.2 in the precursor thin films.

Subsequently, Cd-Sn thin films reacted with phosphorus gas in order to obtain $\text{CdSnP}_2/\text{ZnSnP}_2$ heterojunction. The substrate temperature was about 350 °C and the duration time for phosphidation was 30 min. In the experiments, we used two-phase sample with Sn and Sn_4P_3 as a phosphorus source and phosphorus gas was transported to the precursor samples using deoxygenated Ar gas. The partial pressure of phosphorus was controlled to be approximately 10^{-2} atm by controlling the temperature of the two-phase sample. The cross-sectional observation was carried out using scanning transmission electron microscopy with energy dispersive X-ray analysis (STEM-EDX, JEM-2100F, JEOL) and selected area electron diffraction (SAED) patterns were obtained using a transmission electron microscope (TEM, JEM-2100F, JEOL) to investigate the interfacial structure. The thin samples for the cross-sectional observation were prepared by focused ion beam process with Ga ion source (FIB, SMI 9200 SII). In order to investigate the current density–voltage (J – V) characteristics of $\text{CdSnP}_2/\text{ZnSnP}_2$ junction, Sn and Cu

electrodes with the thickness of about 0.5 μm were deposited by DC-sputtering on CdSnP_2 and ZnSnP_2 sides, respectively, for Ohmic contacts. Sn (99.99%, Furuuchi Chemical Corporation) and Cu (99.99%, Furuuchi Chemical Corporation) were used as the target materials. And the sample was sealed in an evacuated quartz ampule and annealed at 300 $^{\circ}\text{C}$ for 20 min.⁵ The J – V characteristics of $\text{CdSnP}_2/\text{ZnSnP}_2$ junction were measured in the voltage range from -1.5 V to 1.5 V using a digital sourcemeter (Keithley, model2400).

3. Results and discussion

Figure 1 shows cross-sectional STEM images and corresponding elemental mappings of the samples before and after phosphidation. Before phosphidation, it is observed that the Cd-Sn precursor thin film was deposited on the ZnSnP_2 bulk crystal with rough morphology as shown in **Figure 1 (a)**. From the contrast between Cd-L and Sn-L in the elemental mappings, it can be recognized that Cd and Sn particles were separated, particularly understandable around center area, which was also observed on the glass substrates in our previous work²⁴. It is consistent with that the phase diagram of the Cd-Sn system is a typical eutectic diagram.²⁵ **Figure 1 (b)** shows the formation of compounds or alloys containing Cd, Sn and P on the ZnSnP_2 bulk crystal by phosphidation. This

indicates the formation of $\text{CdSnP}_2/\text{ZnSnP}_2$ junction when considering together with SAED pattern shown later. Comparing the STEM images before and after phosphidation, it is observed that the original boundary between Cd-Sn precursor thin film and ZnSnP_2 bulk crystal changed from flat to curved boundary. In addition, Zn was also detected in the Cd-Sn-P region. On the other hand, the junction was inhomogeneously formed and the precipitation of Sn was observed at the interface as shown in Figure 1 (c). Figures 1 (b) and 1 (c) are different areas in the same sample. The realization of homogeneous interfacial structure is thus required as future works. The phosphidation is unsuitable for smooth interface because of the roughness of Cd-Sn precursor films, and then deposition methods such as molecular beam epitaxy (MBE) is desirable.

Then, TEM observation was carried out and SAED patterns were taken from each region around the interface to investigate the crystal structure, as shown in Figure 2. ZnSnP_2 $\langle 110 \rangle$ was selected as the zone axis. The SAED patterns in ZnSnP_2 and Cd-Sn-P regions show the same pattern, indicating that the crystal structure in the Cd-Sn-P region is same as ZnSnP_2 . In other words, CdSnP_2 with chalcopyrite structure was grown on ZnSnP_2 by phosphidation. In addition, both phosphides show the same orientation and thus the epitaxial relationship between CdSnP_2 and ZnSnP_2 is understood. From the viewpoint of carrier transport in photovoltaic devices, such an epitaxial growth is

considered to be favourable to achieve a higher conversion efficiency. On the other hand, the SAED pattern at the interface shown in **Figure 2 (c)** seems to be an overlap of those taken from ZnSnP_2 and CdSnP_2 regions. To investigate the detailed structure at the $\text{CdSnP}_2/\text{ZnSnP}_2$ interface, the composition analysis based on STEM-EDX was carried out. **Figure 3** shows the composition distribution across the interface of $\text{CdSnP}_2/\text{ZnSnP}_2$. The composition was evaluated based on the Cliff-Lorimer method, where Sn was selected as the base element and k -factor of Zn and P were calculated using the ZnSnP_2 bulk crystal region, and that of Cd was obtained using the CdSnP_2 bulk crystal sample separately prepared. The compositions of P and Sn are approximately 50 and 25 at. %, respectively, independent of the scanned positions except for the surface, and **the composition change** of Zn and Cd is observed. This means that the formation of the solid solutions between CdSnP_2 and ZnSnP_2 , $(\text{Cd,Zn})\text{SnP}_2$, which is also supported by the SAED pattern at the interface as shown in **Figure 2 (c)**. The concentration change is continuous and the interface with less lattice defects might be formed. In addition, in the CdSnP_2 region, the concentration of Zn is at least 5 at.%, which correspond to the mole fraction $[\text{Zn}]/([\text{Cd}]+[\text{Zn}])$ of 0.2. On the other hand, Cd was hardly detected in the ZnSnP_2 bulk crystal side. **In this work, the heat treatment was not carried out after the formation of CdSnP_2 and the above asymmetric composition distribution is due to the Zn diffusion**

into CdSnP₂ region during phosphidation. From the above experimental results, the obtained (Cd,Zn)SnP₂/ZnSnP₂ interface can be recognized as a *homointerface* due to both compounds thermodynamically-indistinguishable although it is considered a *heterointerface* at first sight. It is thus expected that the above diffusion behavior is controlled by experimental conditions such as heat treatment during phosphidation and preparation of precursor thin films, and it is a key to obtain favorable interface for photovoltaic application.

Finally, the J – V characteristics were measured using the sample with the structure of Sn/CdSnP₂/ZnSnP₂/Cu. Figure 4 shows the J – V curves in linear and log scale. As shown in these figures, a rectifying behavior is observed, suggesting the formation of a pn-junction at the n -(Cd,Zn)SnP₂/ p -ZnSnP₂ interface because Cu/ZnSnP₂ and Sn/CdSnP₂ junctions have been known to show an Ohmic behavior in our preliminary works. The conventional J – V relationship for single-diode expressed by the equation (1) was fitted to the measured curve,

$$J = J_0 \left\{ \exp \left[\frac{q(V - R_s J)}{NkT} - 1 \right] \right\} + \frac{V - R_s J}{R_{sh}}, \quad (1)$$

where k is the Boltzmann constant and T is the temperature. Consequently, the diode parameters such as saturation current density, J_0 , ideality factor, N , series resistance, R_s ,

and shunt resistance, R_{Sh} , were evaluated to be $1.41 \times 10^{-8} \text{ A cm}^{-2}$, 1.66, $68.9 \text{ } \Omega \text{ cm}^2$ and $8.50 \times 10^5 \text{ } \Omega \text{ cm}^2$, respectively. Comparing the parameters for CdS/CIGS junction²⁶, the series resistance and the saturation current density are relatively high for photovoltaic application. One of the reasons is inhomogeneity of (Cd,Zn)SnP₂/ZnSnP₂ junction as described in the STEM analysis and it should be established to prepare the uniform junction over the entire interface. The high resistivity of CdSnP₂ prepared by phosphidation²⁴, resulting in high series resistance in Figure 4, should be also considered. The above improvement is required for the detailed analysis for interface such as capacitance-voltage measurements and the device fabrication as future works.

4. Conclusions

In this study, Cd-Sn precursor thin films were prepared on ZnSnP₂ bulk crystals grown by flux method and then CdSnP₂ thin films were formed by the phosphidation method for fabrication of CdSnP₂/ZnSnP₂ junction. STEM-EDX analysis and SAED patterns revealed that CdSnP₂ with chalcopyrite structure was epitaxially grown on ZnSnP₂ bulk crystals. In addition, the diffusion of Zn into CdSnP₂ region during phosphidation was observed, while the concentrations of P and Sn are independent of positions around the interface. The above results indicate that favourable junction was obtained due to the formation of solid solution, (Cd,Zn)SnP₂, in the view point of carrier transport. However, *n*-(Cd,Zn)SnP₂/*p*-ZnSnP₂ junction was inhomogeneous and Sn was precipitated in some areas around the interface, which should be improved in future works. In the *J*–*V* characteristic of the junction, a rectifying behavior was observed although the series resistance and the saturation current density were relatively high. It is thus concluded that the *n*-(Cd,Zn)SnP₂/*p*-ZnSnP₂ junction obtained in this work can be recognized as a *pn-homojunction* and this work is one of fundamentals to have more choices for solar absorbing materials including II-IV-V₂ type compounds.

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■ Figure captions

Figure 1. Cross-sectional STEM images and corresponding elemental mappings of (a) before and (b), (c) after phosphidation.

Figure 2. SAED patterns taken from (a) ZnSnP_2 region, (b) Cd-Sn-P (CdSnP_2) region and (c) $\text{CdSnP}_2/\text{ZnSnP}_2$ interface.

Figure 3. Composition analysis at $\text{CdSnP}_2/\text{ZnSnP}_2$ interface based on STEM-EDX.

Figure 4. J – V characteristics of $\text{CdSnP}_2/\text{ZnSnP}_2$ junction in (a) linear and (b) log scale.

■ Figures

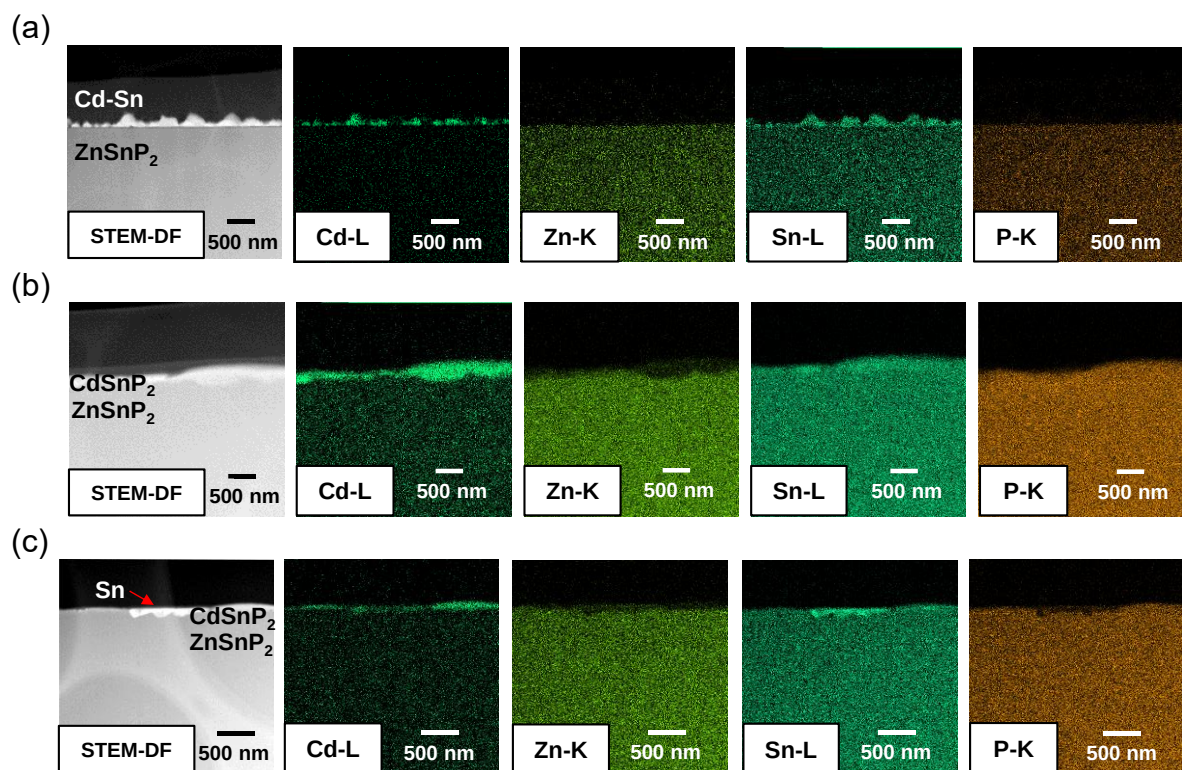


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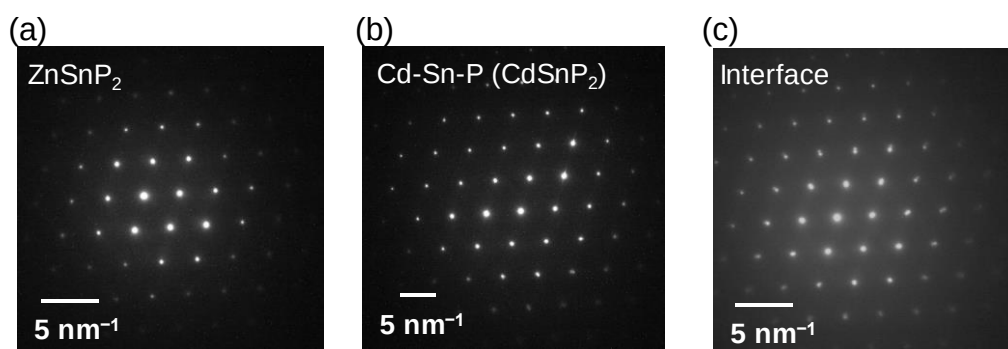


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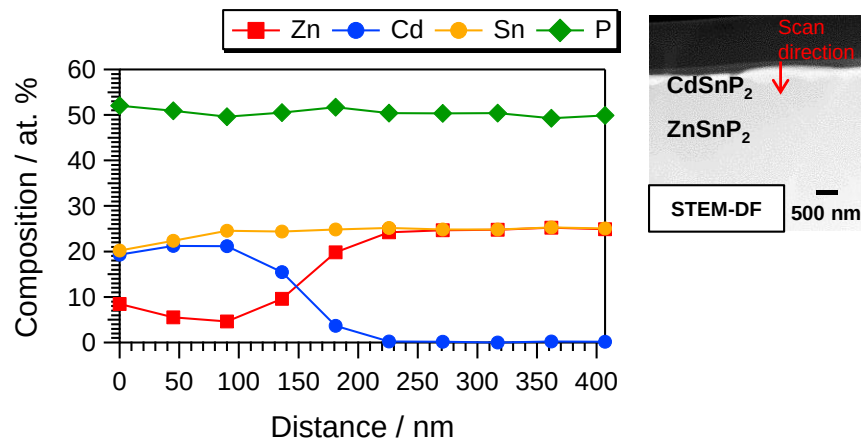


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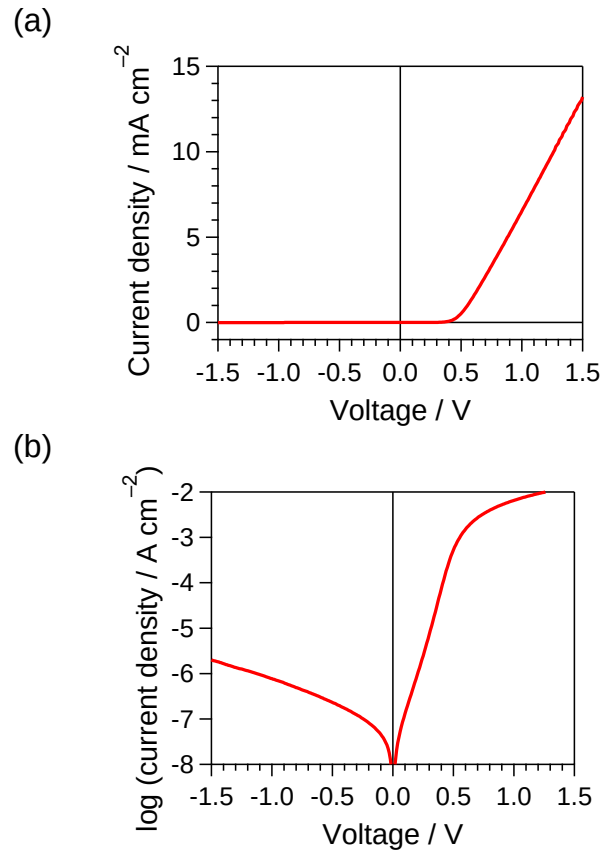


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